HAUG Ionization for the elimination of electrostatic charges



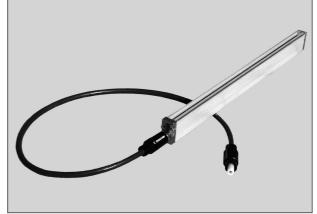
HAUG Ionization systems

are intended to eliminate electrostatic charges. On different material webs, interfering electrostatic charges may form, disturbing production processes and bonding dust particles and other quality-reducing substances to the materials. HAUG has been engaging in research, development and production for 50 years to solve these problems. All industries where materials with low electric conductivity are processed are affected.

EI W

The ionizing bar **EI W** (photo) is a new development combining the highest output with excellent mechanical stability. At the same time, the modular design of the system ensures a high degree of flexibility and serviceability.

The **EI W** eliminates disturbing electrostatic charges at twice the rate of the previously most powerful ionizing bar. This ensures a high level of effectiveness and reliability even with fast-runnning machines and high electrostatic charges. The modular design of the **EI W** allows straightforward and fast replacement of the ionizing pins. Stainless steel pins are used as standard (photo 2). For special applications such as the use of the EI W in semiconductor manufacturing, ionizing pins made of silicon are also available (photo 3).

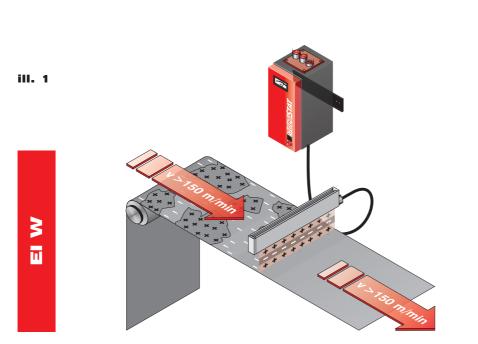


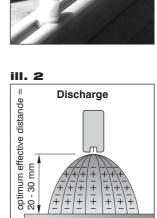


HAUG ionization systems

- consist of the following cpmponents (ill. 1)a power pack with integrated high-voltage transformer and
- one or several connected ionizing units, such as the ionizing bar El W, which are supplied by the power pack with a voltage of 7–8 kV_.

photo 1





Special properties and benefits

- Service-friendly: The HAUG ionizing bar **EI W** consists of individual modules; each part is exchangeable. The high-voltage cable can be extended, shortened or replaced.
- Further reaching: The increased output means that the ionizing bar **EI W** can be installed further away from the material, if required.
- Process compatibility: The material of the ionizing pins can be selected specific to the application. In semiconductor manufacturing, for example, the risk of contamination can be reduced by using ionizing pins made of silicone.

HAUG GmbH & Co. KG

Germany

Friedrich-List-Str. 18 D-70771 Leinf.-Echterdingen Phone: +49 711 / 94 98-0 Telefax: +49 711 / 94 98-298

www.haug.de E-mail: info@haug.de Industries

- <u>Plastic processing industry:</u> film processing, packaging machines, film extruders, etc.
- <u>Textile industry:</u> weaving mills and spinning mills, textile finishing, etc.
- <u>Graphic industry:</u> screen and pad printing machines, photo and film processing machines, folding machines, etc.
- <u>Paint shops:</u> automotive painting, painting of plastic parts, etc.
- <u>Electronic production</u>: insertion of electronic components in circuit boards, production of semiconductor components, production of semiconductors.

HAUG Biel AG

Johann-Renfer-Str. 60 CH-2500 Biel-Bienne 6 Phone: +41 32 / 344 96 96 Telefax: +41 32 / 344 96 97 Switzerland

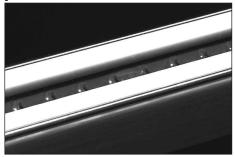
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www.haug-ionisation.com E-mail: info@haug-biel.ch

photo 2



lonizing pins made of stainless-steel

photo 3



lonizing pins made of silicon



Technical data EI W

Туре:	EI W resistance-cou with axial cable HV-cable	1 /
Dimensions:	25 x 45 mm (W x H)	
Length:	80 mm – 2000 mm	
Operating temperature:	+5 °C to +45 °C	
Storage/transport temperature: -15 °C to +60 °C		
Optimum effective distance: 20 – 30 mm (ill. 2)		
Effective length:	bar length - 60	0 mm
Smallest bending radius (cable): R 50		
	Subj	ect to technical changes!
Accessories		

Bar holder

Order-No.: X-0423

Suitable power packs

Connectable lengths (ionizing unit incl. high-voltage cable):EN SLmax. 5 mEN SL LC / EN SL RLCmax. 10 mEN 8 / EN 8 LCmax. 18 mMultistatmax. 18 mEN 70 / EN 70 LCmax. 2 x 18 m

